

Spin-orbit coupling induced by effective mass gradient

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The existence of a spin-orbit coupling (SOC) induced by the gradient of the effective mass in low-dimensional heterostructures is revealed. In structurally asymmetric quasi-two-dimensional semiconductor heterostructures the presence of a mass gradient across the interfaces results in a SOC which competes with the SOC created by the electric field in the valence band. However, in graded quantum wells subjected to an external electric field, the mass-gradient-induced SOC can be finite even when the electric field in the valence band vanishes.

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Semiconductor spintronics is an emerging field based on the controlled manipulation of the carrier spins for data processing and device operations.^{1,2} Most proposals for spintronic devices rely on the ability of manipulating electron spins by using the spin-orbit coupling (SOC), which is the most fundamental spin-dependent interaction in nonmagnetic semiconductors.² In semiconductor heterostructures the SOC results from the lack of inversion symmetry. The bulk inversion asymmetry of zinc-blende semiconductors leads to the so-called Dresselhaus SOC (Ref. 3) while the structure inversion asymmetry (SIA) of the heterostructure itself results in the Bychkov-Rashba (BR) SOC.⁴

In this paper I focus on the investigation of the BR-type SOC and show that, in addition to the SOC generated by the electric field in the valence band,⁵⁻⁷ there is a mass-gradient contribution to the SIA-induced SOC, which, although implicitly contained in some previous calculations,^{2,5-8} has not been recognized till now. In general, the two contributions compete. However, in some specific cases the mass-gradient-induced SOC dominates. It is expected to be particularly relevant in surfaces and metal/semiconductors interfaces, where the effective mass has strong and sharp changes. The identification of the mass-gradient contribution not only clarifies the nature and origin of the SIA-induced SOC but could also lead to new control mechanisms for spin manipulation in heterostructures.

The emergence of SOC due to the existence of a mass gradient can be better understood by establishing an analogy between the nonrelativistic limit of Dirac's theory and the effective-mass Hamiltonian for conduction electrons in semiconductor heterostructures. For simplicity and without loss of generality, I consider the case of a time-independent system in the presence of an electrostatic potential V . Starting with the time-independent Dirac equation the upper ψ_u and lower ψ_l components of the four-component spinor $\Psi = (\psi_u, \psi_l)^T$ are found to be coupled through the equations⁹

$$(\boldsymbol{\sigma} \cdot \mathbf{p})\psi_l = \frac{1}{c}(\epsilon - V)\psi_u, \quad (1)$$

$$(\boldsymbol{\sigma} \cdot \mathbf{p})\psi_u = \frac{1}{c}(\epsilon - V + 2m_0c^2)\psi_l, \quad (2)$$

where ϵ is the particle energy (measured from the rest energy m_0c^2), $\boldsymbol{\sigma}$ is the vector of Pauli matrices and \mathbf{p} , m_0 , and c ,

refer to the momentum operator, the bare electron mass, and the velocity of light, respectively. It follows from Eq. (2) that ψ_l is smaller than ψ_u by a factor $\sim v/c$. Thus, in the nonrelativistic limit ($v \ll c$) the main contribution to the four-component spinor comes from ψ_u . Using Eq. (2) one can eliminate ψ_l from Eq. (2) and obtain, after some algebra, an equation that involves only ψ_u ,

$$\left\{ \mathbf{p} \cdot \left(\frac{1}{2\mu} \mathbf{p} \right) + \frac{\hbar}{2} \left[\boldsymbol{\nabla} \left(\frac{1}{\mu} \right) \times \mathbf{p} \right] \cdot \boldsymbol{\sigma} + V \right\} \psi_u = \epsilon \psi_u, \quad (3)$$

where I have introduced the position-dependent potential mass, $\mu = m_0[1 + (\epsilon - V)/2m_0c^2]$. Note that no approximation has been made in deriving Eq. (3). The two-component spinor ψ_u is, however, not normalized. The standard procedure to overcome this problem in the nonrelativistic limit is to introduce a new normalized two-component spinor $\tilde{\psi} = (1 + p^2/8m_0c^2)\psi_u$.⁹ In doing this, however, some approximations have to be made and the Hamiltonian for the normalized spinor $\tilde{\psi}$ acquires additional terms.⁹ However, these additional terms are irrelevant for our discussion here and will be omitted in our analysis.

The Hamiltonian in Eq. (3) is Hermitian and resembles the effective-mass Hamiltonian describing the motion of electrons in a solid with position-dependent effective mass. Interestingly, the spin-orbit coupling seems to originate from the gradient of the potential mass μ . In the Dirac theory the energy gap, $E_0 = 2m_0c^2$, which separates the energy spectra of the free particles and antiparticles is a position-independent constant. Therefore, the only position dependence in μ which can lead to a finite SOC has to come from the electrostatic potential V . Thus, in the Dirac theory, the SOC emerges purely from the electric field $\mathbf{E} = (-1/e)\boldsymbol{\nabla}V$ (here e denotes the electron charge). In the nonrelativistic approximation the dominant energy is the vacuum gap E_0 and the inverse potential mass can be approximated as $\mu^{-1} \approx m_0^{-1} + (V - \epsilon)/2m_0^2c^2$. As a result the SOC reduces to the well-known form⁹

$$H_{\text{so}} = \frac{\hbar}{2} \left[\boldsymbol{\nabla} \left(\frac{1}{\mu} \right) \times \mathbf{p} \right] \cdot \boldsymbol{\sigma} \approx \frac{\hbar c^2}{E_0^2} (\boldsymbol{\nabla}V \times \mathbf{p}) \cdot \boldsymbol{\sigma}. \quad (4)$$

In the case of semiconductors the analog to the potential mass μ is the effective mass m^* while the equivalent to the

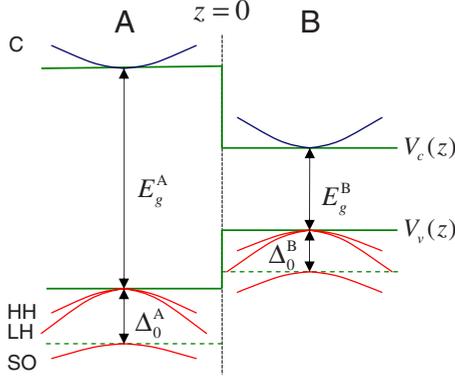


FIG. 1. (Color online) Schematic of the band-edge profile of an A/B semiconductor interface located at $z=0$. The conduction, heavy hole, light hole, and split-off bands are labeled as C, HH, LH, and SO, respectively.

vacuum gap E_0 is the energy gap E_g separating the energy spectrum of electrons in the conduction band from the hole spectrum in the valence band. In contrast to the vacuum, where E_0 is a constant, in semiconductor heterostructures the energy gap E_g becomes position dependent. Therefore, the position dependence of the effective mass may originate from both the electrostatic potential V and the band gap E_g . As a result, in addition to the conventional SOC produced purely by the electric field a finite SOC contribution induced by the position dependence of the effective mass emerges.

To investigate in more details the mass-gradient-induced SOC, I consider a semiconductor heterostructure grown in the z direction. In such a case the mass-gradient-induced SOC can be related to the well-known BR SOC observed in quasi-two-dimensional (2D) systems with SIA.⁴

The effective Hamiltonian describing the motion of the conduction-band electrons in the heterostructure can be obtained by using the envelope function approximation. I consider the (8×8) Kane Hamiltonian^{2,6,10} which accounts for the Γ_{6c} , Γ_{8v} , and Γ_{7v} bands (see bands C, HH and LL, and SO bands, respectively, in Fig. 1). The conduction- and valence-band states can be decoupled by using the folding-down (Löwdin) technique.^{2,6,11} Neglecting the nonparabolicity effects, the effective Hamiltonian for the conduction electrons is found to be^{2,5,8}

$$H_{\text{eff}} = \frac{p_{\parallel}^2}{2m^*(z)} - \frac{\hbar^2}{2} \frac{d}{dz} \left[\frac{1}{m^*(z)} \frac{d}{dz} \right] + V_c(z) + H_{\text{so}}, \quad (5)$$

where

$$\frac{1}{m^*(z)} = \frac{1}{m_0} - \frac{2\tilde{P}^2}{3m_0^2} \left[\frac{2}{V_v(z)} + \frac{1}{V_v(z) - \Delta_0(z)} \right] \quad (6)$$

is the z -dependent, inverse effective mass for the conduction band electrons and

$$H_{\text{so}} = \frac{\alpha(z)}{\hbar} (p_y \sigma_x - p_x \sigma_y) \quad (7)$$

with

$$\alpha(z) = \frac{\hbar^2}{3m_0^2} \frac{d}{dz} \left[\frac{\tilde{P}^2}{V_v(z)} - \frac{\tilde{P}^2}{V_v(z) - \Delta_0(z)} \right] \quad (8)$$

is the SIA-induced SOC. In the equations above p_x and p_y are the components of the in-plane momentum \mathbf{p}_{\parallel} and $\tilde{P} = \langle S | p_x | P \rangle$ represents the nonvanishing momentum matrix elements involving the s -like band edge Bloch state ($|S\rangle$) of the conduction band and the p -like hole states ($|P\rangle = |X\rangle, |Y\rangle, |Z\rangle$). The correction to the effective mass due to the interaction with remote bands can be included by using perturbation theory.^{6,12} As shown in Fig. 1, $\Delta_0(z)$ refers to the spin-orbit splitting energy while $V_c(z)$ and $V_v(z)$ are the potential profiles of the conduction- and valence-band edges, respectively.

For the case of a quantum well grown along the z direction one can obtain an effective Hamiltonian describing the in-plane motion of a two-dimensional electron gas by averaging Eq. (5) with the spin-independent z component, $f(z)$, of the wave function. This results in the so-called BR SOC with $\alpha_{\text{BR}} = \langle \alpha(z) \rangle_c = \int \alpha(z) |f(z)|^2 dz$ as the BR SOC strength.

At first glance it seems that the BR spin splitting should be proportional to the electric field which breaks the spatial inversion symmetry. However, the fact that for quasi-2D systems with position-independent effective mass the electric field along the direction of confinement must average to zero¹³ (this follows from Ehrenfest's theorem which states that the average force on a bound state vanishes¹⁴) generated intensive discussions about the nature of the electric field causing the BR SOC.^{5,13,15,16} It was later found that for a quantum-well growth along the z direction, with z -dependent effective mass, the average electric field $E_c \sim \langle p_z [(\partial_z m^{-1}) p_z] \rangle_c$ may not vanish.¹⁷ However, the estimated value for this field was found to be too small^{16,17} as to explain the experimentally observed spin splitting due to the SIA SOC. Actually, the SOC induced by E_c represents a high-order correction which is not even present in the effective Hamiltonian obtained with the standard (8×8) Kane approximation.

In an attempt to clarify the origin of the BR SOC, Lassnig⁵ showed that the BR spin splitting in the conduction band is related to the electric field in the valence band [$\mathbf{E}_v = (-1/e) \nabla V_v$] whose average (over the conduction states) does not necessarily vanish (note that in this case Ehrenfest's theorem does not apply^{6,7}). Below I show that in addition to the SOC induced purely by \mathbf{E}_v a contribution originating from the existence of a mass gradient appears. I remark, however, that the mass-gradient contribution discussed here is much larger than the one generated by the mass-gradient-induced electric field E_c (see discussion in the previous paragraph) and appears readily in the effective Hamiltonian resulting from the (8×8) Kane model. In fact, the BR SOC can be reinterpreted as resulting from the competition between the here-proposed mass-gradient SOC and the SOC induced purely by \mathbf{E}_v . Interestingly, the mass-gradient contribution (and therefore the BR SOC) can be finite even when the electric field in the valence band vanishes (i.e., $\mathbf{E}_v = 0$).

Combining Eqs. (6) and (8) one can rewrite the SOC parameter as

$$\alpha(z) = \frac{\hbar^2}{2} \frac{d}{dz} \left[\frac{1}{m^*(z)} \right] + \frac{\hbar^2}{m_0^2} \frac{d}{dz} \left[\frac{\tilde{P}^2}{V_v(z)} \right]. \quad (9)$$

When modeling semiconductor heterostructures, the momentum matrix element, \tilde{P} , is commonly considered to be position independent.⁶ Within this approximation and taking into account that for most semiconductors V_v is of the same order of the band gap (i.e., $|V_v - E_g| \ll E_g$, one can approximate Eq. (9) as¹⁸

$$\alpha(z) = \frac{\hbar^2}{2} \frac{d}{dz} \left[\frac{1}{m^*(z)} \right] - \frac{\hbar^2 (\tilde{P}/m_0)^2}{E_g^2} \frac{d}{dz} V_v(z). \quad (10)$$

Thus, one can rewrite the SOC in Eq. (7) as $H_{\text{so}} = H_{\text{so}}^m + H_{\text{so}}^v$, where

$$H_{\text{so}}^m = \frac{\hbar}{2} \left[\nabla \left(\frac{1}{m^*} \right) \times \mathbf{p} \right] \cdot \boldsymbol{\sigma} \quad (11)$$

is the mass-gradient-induced SOC and

$$H_{\text{so}}^v = - \frac{\hbar (\tilde{P}/m_0)^2}{E_g^2} (\nabla V_v \times \mathbf{p}) \cdot \boldsymbol{\sigma} \quad (12)$$

is the SOC created by the electric field in the valence band.

Equation (12) has the same structure as Eq. (4),¹⁸ which confirms that, indeed, H_{so}^v corresponds to the *standard* SOC generated, purely, by an electric field; in this case by the valence-band electric field $\mathbf{E}_v = (-1/e) \nabla V_v$. Consequently, H_{so}^v vanishes when $\mathbf{E}_v = 0$. On the contrary, it is clear from Eqs. (6) and (11) that even in the case of vanishing \mathbf{E}_v , the mass-gradient-induced SOC, H_{so}^m , remains, in general, finite.

The SOC strength in semiconductor heterostructures is usually evaluated^{2,5-8} by using Eq. (8), which already contains, implicitly, the mass-gradient contribution [note that Eqs. (8) and (10) are equivalent]. However, since the physical interpretation of Eq. (8) is obscure, the mass-gradient contribution has not been recognized till now. By rewriting Eq. (8) in the form of Eq. (10), the physical meaning of each of the contributions to the total SOC become apparent. The mass-gradient-induced SOC emerges then naturally, at the same level as the SOC generated by the valence-band electric field.

For an estimation of the strengths of the mass-gradient and valence-band electric field-induced SOC, I consider the case of an A/B abrupt interface between two III-V semiconductors (see Fig. 1). In such a case the band parameters, and therefore m^* and V_v , are steplike functions of z and the mass-gradient and valence-band electric field-induced SOC in Eq. (9) reduce to

$$H_{\text{so}}^{m,v} = \frac{\alpha_{m,v}}{\hbar} \delta(z) (p_y \sigma_x - p_x \sigma_y) \quad (13)$$

with

TABLE I. Interface spin-orbit coupling parameters (in eV Å²) for A/B abrupt interfaces containing arsenides. α_m and α_v correspond to the contributions due to the mass gradient and valence-band electric field, respectively, while α_{int} is the total interface SOC strength.

A	B	α_m	α_v	α_{int}
GaAs	AlAs	-35.88	39.07	3.19
Ga _{0.47} In _{0.53} As	Al _{0.48} In _{0.52} As	-33.39	62.09	28.7
Ga _{0.47} In _{0.53} As	InP	-40.68	62.73	22.05

$$\alpha_m = \frac{\hbar^2}{2} \left(\frac{1}{m_B^*} - \frac{1}{m_A^*} \right) \quad (14)$$

and

$$\alpha_v = \frac{\hbar^2}{m_0^2} \left(\frac{\tilde{P}_A^2}{E_g^A} - \frac{\tilde{P}_B^2}{E_g^B} \right), \quad (15)$$

respectively. Here the values of the parameters in regions A and B are indicated with the respective labels. Note also, that for a better accuracy, the steplike position dependence of the momentum matrix element has also been considered in Eq. (15).

The calculated values of α_m , α_v , and the total interface SOC strength, $\alpha_{\text{int}} = \alpha_m + \alpha_v$, for some, experimentally relevant,¹⁹⁻²¹ interfaces are listed in Table I. For all the considered interfaces, α_m and α_v are of the same order but with opposite signs. Thus, the competition between the mass-gradient and valence-band electric field-induced SOC contributions results in the overall decrease in the total interface SOC.

In systems in which α_m and α_v are of the same order (as the ones considered above) the mass-gradient contribution to the SOC is masked by the SOC induced by the valence-band electric field. Therefore the experimental measurement of α_m alone may be difficult in such systems. To overcome this problem, I propose to measure α_m in a graded, semiconductor quantum well subjected to an external electric field.

For illustration, I consider a Ga_{1-x}Al_xAs-based quantum well with high-potential barriers so that interface effects play a little role and can be neglected. In a linearly graded quantum well (i.e, with Al concentration varying linearly with the position) the energy gap together with the band parameters become position dependent. For small grading, the band parameters interpolate linearly with the Al concentration. Consequently, both the potential profile of the conduction (V_c^0) and valence (V_v^0) band edges change linearly with z [see Fig. 2(a)]. In the presence of a constant external electric field, \mathbf{E}_{ext} , oriented along the growth direction the band-edge profiles are modified as $V_c = V_c^0(z) - eE_{\text{ext}}z$ and $V_v = V_v^0(z) - eE_{\text{ext}}z$. Since $V_v^0(z)$ is a linear function of z one can find a *target* electric field for which V_v becomes position independent and the total electric field in the valence bands vanishes [see Fig. 2(b)]. Therefore, for such a target external field, $\alpha_v \approx 0$, while α_m remains finite. Under this condition, the SOC is determined solely by the mass-gradient contribution.

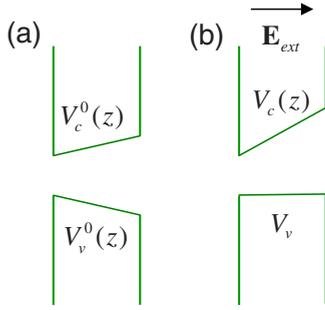


FIG. 2. (Color online) Schematics of the conduction- and valence-band potentials in a linearly graded quantum well with infinite barriers, in the (a) absence and (b) presence of an external electric field \mathbf{E}_{ext} . The external electric field compensates the electric field in the valence band in such a way that the total electric field in the valence band vanishes (i.e., $\nabla V_v = 0$).

I now estimate the values of $\bar{\alpha}_m$ (the bar sign stands for position average) and the target external field E_{target} for a quantum well with Al concentration varying linearly from $x_{min}=0$ to $x_{max}=0.1$, i.e.,

$$x(z) = x_{max}z/d. \quad (16)$$

Here $d=200 \text{ \AA}$ is the well width. The composition dependence of the band parameters is evaluated according to the interpolation scheme developed in Ref. 12. I then expand Eq. (6) up to the linear order in x [which for the small concentrations considered here ($x \leq 0.1$) suffices] and obtain the position dependence of the inverse effective mass by using Eq. (16). For the target external field $E_{target} \approx 30 \text{ kV/cm}$ the valence-band electric field vanishes (i.e., $\bar{\alpha}_v=0$) while the strength of the mass-gradient-induced SOC is found to be

$\bar{\alpha}_m \approx -8.74 \text{ meV \AA}$. Apart from the sign, this value is of the same order but still larger than the SIA SOC parameters experimentally measured in GaAs-AlGaAs asymmetric quantum wells.^{19,20}

Beyond the case of semiconductor heterostructures, the mass-gradient-induced SOC is expected to be relevant in surfaces and metal/semiconductor interfaces across which the values of the effective mass have large and abrupt changes. For example, the mass-gradient contribution to the SOC in the L -gap surface state of Au(111) can be easily estimated by using Eqs. (13) and (14), and the experimental values $m^* = 0.25 m_0$ in gold²² ($m^* = m_0$ in vacuum). Assuming that the surface state is localized within the five outermost surface layers (the potential of the sixth surface layer already shows bulk behavior²²) one obtains $\bar{\alpha}_m \approx 323 \text{ meV \AA}$, which is already close to the value 396 meV \AA extracted from experiments.²² This suggests that the mass-gradient SOC gives the dominant contribution in such a system.²³

In summary, the existence of a mass-gradient contribution to the SOC in systems with structure inversion asymmetry is revealed. This contribution can be of the same order as the SOC generated by the electric field in the valence band of semiconductors. However, in the particular case of a linearly graded semiconductor quantum well subjected to a conveniently designed external field, the electric field in the valence band vanishes and the remaining SOC is purely induced by the mass gradient. The relevance of the mass-gradient SOC for surfaces and metal/semiconductor interfaces is briefly addressed.

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